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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Mu-Liang Liao
Chi-Piao Cheng
Te-Sung Hung
Yung-Chieh Kuo

Examiner:

Filing Date: 2004/1/16

Art Unit:

App. No.: 10/707,838

Docket No.: NAUP0511USA0

Title: ALL-IN-ONE POLISHING PROCESS FOR A
SEMICONDUCTOR WAFER

To: Assistant Commissioner for Patents
P.O.BOX 1450
Alexandria, VA 22313-1450

Subject: Request for withdrawal as agent

Dear Sir or Madame:

I hereby apply to withdraw as agent for the above identified patent/patent application. The reason for this request is that I am leaving my current office of employment to attend law school.

Although I am requesting to withdraw from the above patent/patent application, Winston Hsu, agent registration No. 41,526, will continue to serve as the primary agent of record for this case. **This request for withdraw does not affect the status of Mr. Hsu as the principle agent of record for the above-identified case.** Consequently, the correspondence address is NOT affected by this withdrawal. Furthermore, as Mr. Hsu will continue acting as the agent of record, my withdrawing from this case will not affect the client's ability to obtain timely representation. Mr. Hsu, as my employer, has agreed to my withdrawal and will continue handling all aspects of this case. I therefore believe in good faith that the USPTO should find this request for withdrawal acceptable.

Sincerely yours,

Mord Michael Lewis

Date: 7/18/2003

Mord Michael Lewis, Patent Agent No.50,478